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APPLICATION N	NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,524		09/22/2003	Hideomi Koinuma	32307-191598	5810
26694	7590	04/10/2006		EXAMINER	
VENABLE LLP P.O. BOX 34385				MANDALA, VICTOR A	
WASHINGTON, DC 20045-9998				ART UNIT	PAPER NUMBER
				2826	
				DATE MAIL ED. 04/10/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/665,524	KOINUMA ET AL.					
Office Action Summary	Examiner	Art Unit					
	Victor A. Mandala Jr.	2826					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
Responsive to communication(s) filed on 15 M     This action is FINAL. 2b) ☐ This     Since this application is in condition for alloware closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro	•					
Disposition of Claims							
4) ☐ Claim(s) 78-85 is/are pending in the application 4a) Of the above claim(s) is/are withdray 5) ☐ Claim(s) 83-85 is/are allowed. 6) ☐ Claim(s) 78-82 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/o	vn from consideration.						
Application Papers							
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Examine	epted or b) objected to by the bedrewing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).					
Priority under 35 U.S.C. § 119							
<ul> <li>12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents</li> <li>2. Certified copies of the priority documents</li> <li>3. Copies of the certified copies of the priority application from the International Bureau</li> <li>* See the attached detailed Office action for a list</li> </ul>	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on Noed in this National Stage					
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 3/15/06	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:						

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#### **DETAILED ACTION**

### Response to Amendment

- 1. The Applicant has amended the claims in the RCE filed on 3/15/06. The examiner has found and error in the listing of claims where claim 1 is presently amended, but is the same claim as filed on 9/22/05. The examiner is assuming the claim should have been canceled because in the remarks section of the amendment, it states that claim 1 is canceled. The remarks section also does not include any further discussion of the claim in regard to the rejection made in the final office action dated 12/15/06. The rejection of claim 1 will stand as is.
- 2. The Applicant has submitted an IDS filed with the RCE on 3/15/06. The examiner has considered the IDS and has found prior art that reads on some of the current claims. The rejection is stated below.

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 1 is rejected under 35 U.S.C. 103(a) as being unpatentable over Japanese Patent No. 62-181483 Mashahisa.

3. Referring to claim 1, a thin film device comprising, (JAPANESE PATENT ABSTRACT): a metal sulfide layer selected from the group consisting of manganese sulfide (MnS), magnesium sulfide (MgS), and calcium sulfide (CaS), (Figure 1 #4 Abstract Constitution line 6 CaMgS), which is formed on a single crystal silicon substrate, (Figure 1 #1), by epitaxial

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growth, (Abstract Constitution lines 1-3); and a thin film comprising an ionic compound, (Figure 1 #6 TaO Abstract Constitution line 8), which is formed on the metal sulfide, (Figure 1 #4), layer by epitaxial growth, (See \*\* below).

\*\* Initially and with respect to claim 1, note that a "product by process" claim is directed to the product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Fitzgerald, 205 USPQ 594, 596 (CCPA); In re Marosi et al., 218 USPQ 289 (CAFC); and most recently, In re Thorpe et al., 227 USPQ 964 (CAFC, 1985) all of which make it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that Applicant has burden of proof in such cases as the above case law makes clear.

As to the grounds of rejection under section 103, see MPEP § 2113

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

Claims 78-82 are rejected under 35 U.S.C. 102(a) as being anticipated by Japanese Patent Application No. 2002-003297 with English Abstract.

Referring to claim 78, a thin film device comprising: a metal sulfide layer selected from the group consisting of manganese sulfide (MnS), magnesium sulfide (MgS), and calcium sulfide (CaS), (Figure 1 #2 English Abstract CaS, MnS, or MgS), which is formed on a single crystal silicon substrate, (Figure 1 #1), and a thin film comprising an ionic compound, (Figure 1 #4), which is formed on the metal sulfide layer, (Figure 1 #2), wherein the metal sulfide layer, (Figure 1 #2), is sandwiched between said single crystal silicon substrate, (Figure 1 #1), and said

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thin film, comprising an ionic compound, (Figure 1 #4), and wherein said thin film comprising said ionic compound is selected from the group consisting of a metal nitride thin film and a metal oxide film, (Figure 1 #4).

- Referring to claim 79, a thin film device comprising: a metal sulfide layer selected from the group consisting of manganese sulfide (MnS), magnesium sulfide (MgS), and calcium sulfide (CaS), (Figure 1 #2 English Abstract CaS, MnS, or MgS), which is formed on a single crystal silicon substrate, (Figure 1 #1), and a thin film comprising an ionic compound, (Figure 1 #4), which is formed on the metal sulfide layer, (Figure 1 #2); and a platinum group layer, (Figure 1 #3), formed between said metal sulfide layer, (Figure 1 #2), and said thin film comprising said ionic compound, (Figure 1 #4).
- 6. Referring to claim 80, a thin film device, wherein said thin film comprises at least one selected from the group consisting of a metal nitride thin film, a metal oxide thin film, and a metal sulfide thin film, (Figure 1 #4).
- 7. Referring to claim 81, a thin film device, wherein a metal of said platinum group metal is selected from the group consisting of rhodium, iridium, palladium, and platinum or an alloy thereof, and wherein said platinum metal layer is in the form of a single layer or a multi-layer, (Figure 1 #3).
- 8. Referring to claim 82. a thin film device, wherein said ionic compound thin film is selected from the group consisting of a metal nitride thin film, a metal oxide thin film, and a metal sulfide thin film, (Figure 1 #4).

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### Allowable Subject Matter

5. Claims 83-85 are allowed.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Victor A. Mandala Jr. whose telephone number is (571) 272-1918. The examiner can normally be reached on Monday through Thursday from 8am till 6pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

VAMJ 3/30/06

